

Low Output Impedance 0.6 μ m-CMOS Sub-Bandgap Reference

V. Gupta and G.A. Rincón-Mora

Abstract: A 0.6 μ m-CMOS sub-bandgap reference circuit whose output voltage is, unlike reported literature, *concurrently* low voltage and low output impedance is presented. Experimental measurements verify that the proposed circuit, which produces a first-order temperature compensated reference voltage of 890mV, sources up to 5mA of load current and rejects noise by a factor of 30.8-8.1dB at 500kHz-4MHz, neither feature of which is achieved by state-of-the-art sub-bandgap circuits.

Introduction: A low output impedance reference is desirable for noise-sensitive applications to shunt and steer noise away from sensitive nodes and source dc and ac load currents [1-2], which is why most of the references used in industry are variations of the regulated references presented in [3]. Reported regulated references, however, only produce the conventional 1.2V bandgap voltage, or a higher voltage [1-5], which is unsuitable for a growing number of high-end applications that use modern CMOS processes with low breakdown voltages. Alternatively, as shown in Fig. 1, a series linear regulator can buffer the output of a low-voltage, high output impedance reference [6-7]. The buffer, however, introduces additional random and systematic offset components to the reference, significantly degrading the overall accuracy performance of the system; these offsets, for instance, caused an additional ± 4 mV error in [2]. This additional error, which monopolizes 0.4% of a 1V reference, leaves little error budget for the reference itself, which is particularly troubling in CMOS technologies because MOS offsets have a

non-linear dependence to temperature and cannot be compensated with trim. Moreover, a buffer does little to attenuate the noise already present in the high impedance reference, since it simply propagates the disturbance to the output unabated. Generating a sub-bandgap reference voltage with low output impedance characteristics, for which no prior art solution was found to exist, is the objective of this paper.

Proposed Topology: For shunt feedback, which is necessary for low output impedance, the reference must be the sum of temperature-dependent voltages (not currents), as shown in the proposed circuit of Fig. 2(a), where a proportional-to-absolute temperature (PTAT) voltage is sampled and regulated via amplifier OA₁ and power PMOS MP_O. The forward-biased voltage of diode D decreases, for the most part, linearly with temperature and hence has a complementary-to-absolute-temperature (CTAT) behavior. This CTAT voltage is attenuated by the potential divider comprised of resistors R₁₁ and R₁₂ to produce CTAT voltage component V_{X-CTAT} at node V_X.

The amplifier has a pre-set PTAT offset voltage and the loop regulates and impresses this voltage across R₁₃. The temperature-compensated output, shown in Fig. 2(b), is the sum of this PTAT voltage (V_{R-PTAT}), the CTAT diode-derived voltage across R₁₂ (V_{X-CTAT}), and the additional PTAT voltage component across R₁₂ (V_{X-PTAT}), that results from running R₁₃'s PTAT current through R₁₂ (V_{X-PTAT}) and is given by

$$V_{REF} = V_{R-PTAT} + (V_{X-PTAT} + V_{X-CTAT}) = V_{PTAT} + V_{CTAT}. \quad (1)$$

Amplifier OA₁ and pass device MP_O constitute the high loop-gain, shunt-feedback path (A_{ol}β) around V_{REF}. This negative feedback loop regulates the output against variations in input supply and load. Since MP_O is a large PMOS device, the regulated reference can

sustain low supply voltages under relatively high load currents, in other words, yield low dropout voltages.

Complete Schematic: The complete circuit shown in Fig. 3 is comprised of a biasing block and the output stage and amplifier presented in Fig. 2. The bias current is defined by a conventional PTAT generator block. The dominant low-frequency pole of the loop is established at the gate of MP_O through Miller-compensating capacitor C_M .

Key to this circuit is OA_1 's PTAT offset voltage, which is intrinsically defined by input pair QP_{21-22} , whose emitter areas are $8x$ and x , respectively, and current mirror MP_{21-22} , which ensures equal currents flow through QP_{21-22} . The result is a PTAT difference across their base-emitter voltages (i.e., $\Delta V_{BE} = V_T \ln(8)$). The offset voltage across the bases of QP_{21-22} is the voltage divided version of the voltage across R_{13} (V_{R-PTAT}); or equivalently, V_{R-PTAT} is an amplified version of the PTAT voltage present at the bases of QP_{21-22} ,

$$V_{R-PTAT} = \left(\frac{R_{14} + R_{15}}{R_{15}} \right) \Delta V_{BE}. \quad (2)$$

This voltage defines R_{13} 's PTAT current, which ultimately flows into node V_X . Resistors R_{14} and R_{15} therefore implement a voltage divider circuit whose total resistance and series combination is modeled by R_{12} . The first-order temperature compensated reference voltage is consequently given by

$$V_{REF} = K_1 V_{BE} + K_2 K_3 \Delta V_{BE} = K_1 \left(V_{BE} + \frac{K_2 K_3}{K_1} \Delta V_{BE} \right), \quad (3)$$

where K_1 , K_2 , and K_3 are

$$K_1 = \frac{(R_{14} + R_{15}) \parallel R_{12}}{[(R_{14} + R_{15}) \parallel R_{12}] + R_{11}}, \quad (4)$$

$$K_2 = \frac{R_{14} + R_{15}}{R_{15}}, \quad (5)$$

and

$$K_3 = 1 + \frac{R_{11} \parallel R_{12} \parallel (R_{14} + R_{15})}{R_{13}}. \quad (6)$$

The lateral PNP devices of the process were characterized for parameters like forward beta (BF), Early voltage (VAF), and saturation current (IS), among others. The values of these parameters were found to be 100A/A, 6V, and 3fA, respectively. This high beta allows base currents to be neglected while deriving Eq. (2)-(6).

Results: The proposed circuit was fabricated with AMI's 0.6 μ m CMOS process technology ($V_{TN} \approx 0.7V$ and $|V_{TP}| \approx 0.9V$) through the MOSIS design facility. The temperature coefficient of 20 samples, showing a sub-bandgap output of 890.5mV, is presented in Fig. 4(a). The transient load-induced variation of the reference when subjected to a load current step of 0-5mA with 100ns rise and fall times, shown in Fig. 4(b), is a measure of the circuit's ability to suppress load-dump effects.

To gauge the noise-shunting capabilities of the proposed circuit against the state-of-the-art, a current-mode 890mV sub-bandgap reference was built by sourcing 49 μ A into an 18k Ω -10pF output resistor-capacitor combination, as illustrated in Fig. 5(a). To emulate noise injection through parasitic coupling capacitors, a noise current of roughly 125 μ A was injected into the reference (state-of-the-art $V_{REF-SOA}$ and proposed V_{REF}), as shown in Figs. 5(a) and 5(b). A comparison of the transient response of the two circuits (Fig. 5(c)) shows how the proposed reference suppresses most of the broadband ac noise

injected, quickly recovering its output to the desired level. The frequency spectra of the two waveforms (Fig. 5(d)) reveal that the proposed circuit (V_{REF}) further rejects noise by a factor of 30.8-8.1dB ($V_{REF-SOA}$ -to- V_{REF} noise power ratio) at 500kHz-4MHz.

Conclusions: A 0.9V, 34.7ppm/°C, 5mA, low output impedance 0.6 μ m CMOS sub-bandgap reference has been designed, fabricated, and evaluated. The principal features of the proposed circuit are low impedance and sub-bandgap output voltages, concurrently, the combination of which was not found in literature, patents, or commercial products without the use of series shunt-regulators, which degrade accuracy.

References

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Figure Captions

Fig. 1. Reference-regulator low impedance circuit and its adverse treatment of noise and offset.

Fig. 2. (a) Concept and (b) temperature behavior of proposed reference.

Fig. 3. Complete schematic of proposed low impedance, sub-bandgap reference.

Fig. 4. (a) Temperature dependence of trimmed samples and (b) transient load regulation.

Fig. 5. Noise rejection measurements: set-up for (a) the state-of-the-art sub-bandgap reference and (b) proposed circuit and corresponding ac-coupled (c) transient and (d) frequency ($V_{\text{REF-SOA-to-}V_{\text{REF}}}$ noise power ratio) response.

Figure 1

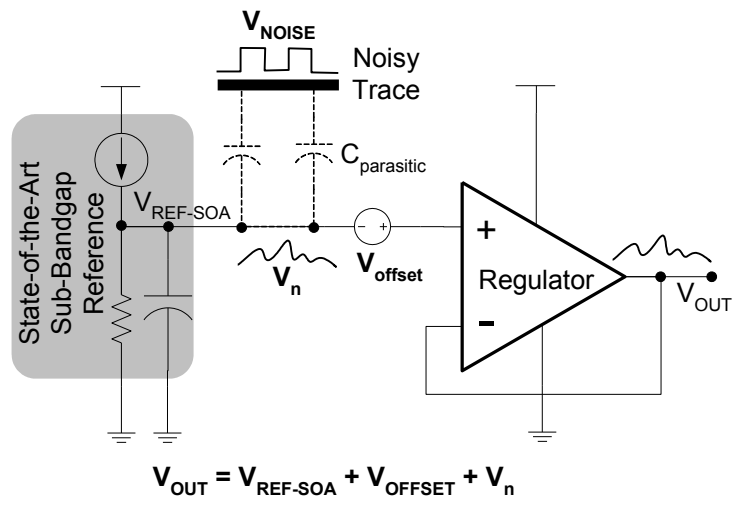


Figure 2

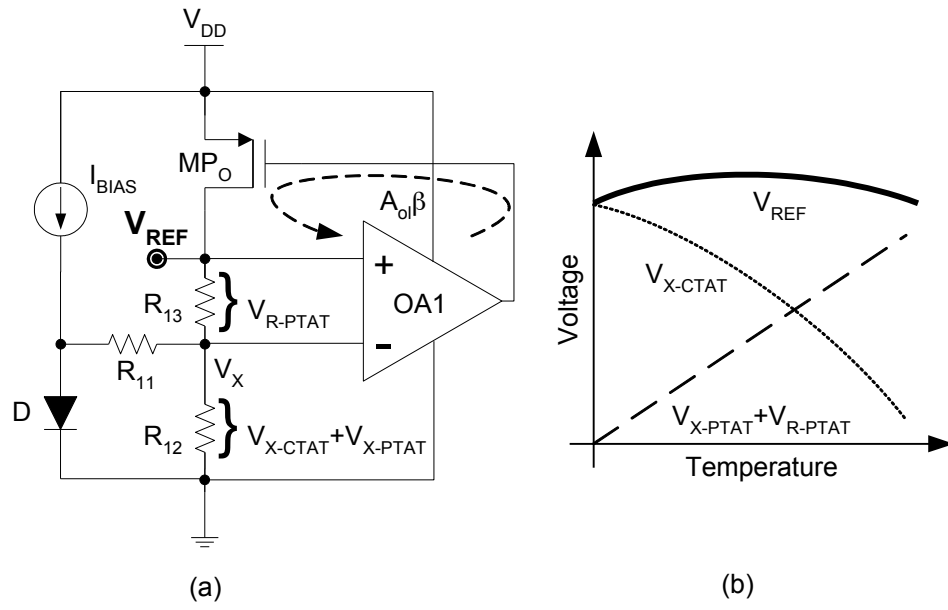


Figure 3

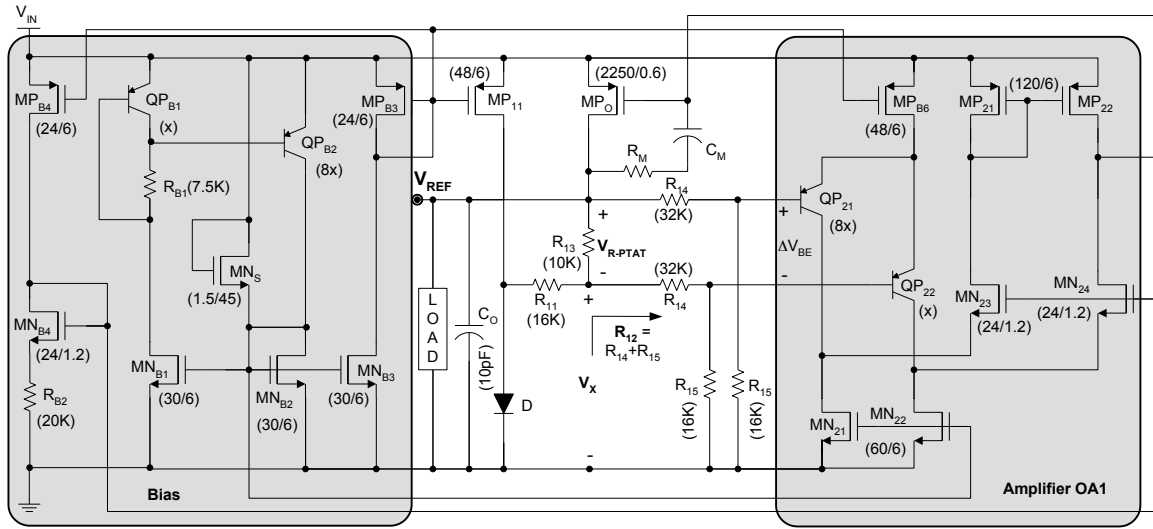
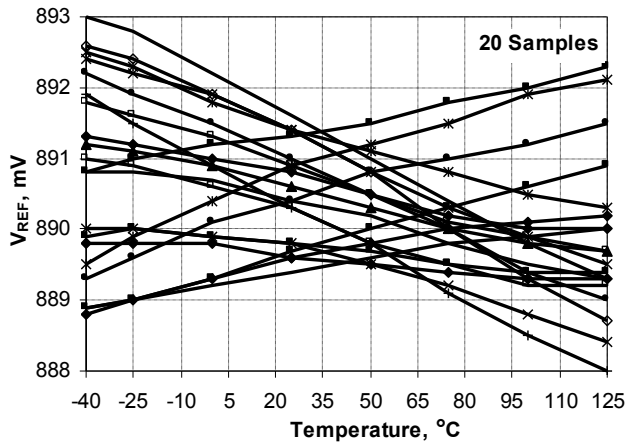
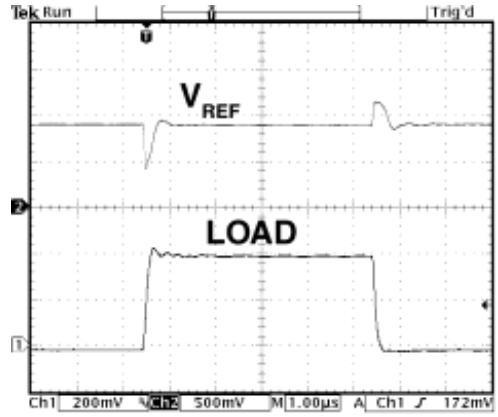


Figure 4



(a)



(b)

Figure 5

